A ZnO/N-doped carbon nanotube nanocomposite charge transport layer for high performance optoelectronics†

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Metal oxide charge transport layers are widely used to promote the interfacial charge transport of organic optoelectronics. Nevertheless, frequently used wide-bandgap metal oxides with low electrical conductivities reveal inherent limitations in the charge transport enhancement. We present the remarkable electro-conductivity enhancement of solution processable ZnO charge transport layers upon dispersing a tiny amount (less than 0.1 wt%) of chemically doped CNTs and the corresponding device performance improvement of light-emitting diodes (OLEDs). Using various undoped or doped CNTs, whose work function was systematically tuned by substitutional doping of electron deficient B or electron rich N,N-doped CNT (N-CNT), the composite showed a lowered work function matching well with the conduction band of ZnO. Consequently, the ZnO/N-CNT nanocomposite transport layer with 0.08 wt% N-CNT showed a five-fold enhancement of electron mobility, while maintaining the intrinsic bandgap energy levels, optical transparency and solution processability of pure ZnO. The inverted OLEDs employing ZnO/N-CNT nanocomposite electron transport layers could facilitate well-balanced electron–hole injection and, thus, more than two-fold enhancement of maximum luminance (from 21 000 cd m⁻² at 14.6 V to 46 100 cd m⁻² at 14.0 V) and efficiency (from 6.9 cd A⁻¹ at 13.4 V to 14.3 cd A⁻¹ at 13.6 V). This highly effective charge mobility enhancement enabled by work function tunable, chemically doped CNTs would be beneficial for various organic and inorganic charge transport materials with different energy levels.

Introduction

The interfacial charge transport layer is an essential device element for high performance optoelectronics.1–3 A charge transport layer

† Electronic supplementary information (ESI) available: XPS analysis of undoped and doped CNTs, preparation of homogeneously dispersed ZnO/CNT precursor solutions, light-emitting characteristics of OLEDs with various concentrations of N-CNTs in the ZnO layer, J–V characteristics of electron-only devices with various concentrations of N-CNTs in the ZnO layer, the bandgap energy of ZnO/CNT nanocomposite layers obtained from the UV–VIS absorption spectrum, the work function measurement of undoped and doped CNTs by UPS. See DOI: 10.1039/c2jm30710c

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a severe deformation.\textsuperscript{25–27} Such attractive characteristics render graphitic carbon materials as valuable component materials for organic optoelectronics.\textsuperscript{28} Nevertheless, previous research efforts for the optoelectronic application have suffered from the poor tunability of the work function (4.7–5.2 eV) caused by the use of the inert graphitic chemical structure.\textsuperscript{29,30} A mismatched and uncontrollable work function makes it hard to engineer the interfacial energy level and to optimize charge transport in optoelectronic devices. To date, several approaches have been explored to modulate the work function of graphitic carbon materials, including the physisorption of ions,\textsuperscript{31} molecules,\textsuperscript{32} or nanoparticles.\textsuperscript{33} In those approaches, however, the desorption of the physisorbed dopants may cause deterioration of device performance in long-term operations.

In this work, we demonstrate a robust pathway to enhance the electrical conductivity of solution processable metal oxide charge transport layers, while maintaining their intrinsic energy levels, by dispersing substitutionally doped CNTs. The substitutional doping of electron-deficient boron (B) or electron-rich nitrogen (N) systematically altered the work function of CNTs and endured high temperature treatment involved in the solution processing of thin ZnO/CNT nanocomposite layers via spray-pyrolysis.\textsuperscript{34,35} Among various undoped or doped CNTs, N-doped CNT (N-CNT) showed a work function closely matching the conduction band of ZnO to form an ohmic contact for electron transport.\textsuperscript{36} The resultant ZnO layer with finely dispersed, high mobility N-CNTs demonstrated remarkable enhancement of electron mobility. Unlike widely used atomic scale foreign element doping, nanocomposites employing high carrier mobility nanomaterials did not alter the intrinsic energy level of metal oxides. The ZnO/N-CNT nanocomposite layer with improved electron mobility enabled balanced electron and hole injection, and device performance optimization of inverted organic light-emitting diodes (OLEDs).

\section*{Experimental}

\subsection*{B- and N-doping of multi-walled CNTs}

Commercially available CNTs (>95\%, multi-walled nanotubes) grown by chemical vapor deposition (CVD) were purchased from Hanwha Nanotech. The average diameter of CNTs was 10–15 nm. 1 g of CNTs was sonicated in 500 mL strong acid solution (3 : 1 mixture of HNO\textsubscript{3} and H\textsubscript{2}SO\textsubscript{4}) for 10 hours and then washed with deionized (DI) water and filtered for purification. After drying, the CNTs were thermally treated at 400 °C for 40 min to remove amorphous carbons. The average length of the purified CNTs was less than 1 μm. For B-doping, the purified CNTs were mixed with powdered B\textsubscript{2}O\textsubscript{3} and placed in an open sintered pure graphitic crucible. The weight ratio of B\textsubscript{2}O\textsubscript{3} : CNTs in the crucible was 5 : 1. The B\textsubscript{2}O\textsubscript{3}–CNT mixture was thermally treated at 1100 °C for 4 hours under an Ar (40 sccm)/NH\textsubscript{3} (60 sccm) gas flow. After thermal treatment, the remaining B\textsubscript{2}O\textsubscript{3} powder was washed with hot boiled DI water. For N-doping, the purified CNTs in the crucible were thermally treated at 1100 °C for 4 hours under Ar (40 sccm)/NH\textsubscript{3} (60 sccm) gas flow.

\subsection*{ZnO/CNT precursor solution preparation}

The zinc acetate dihydrate (Sigma-Aldrich, 16.5 mg) was dissolved in 2-methoxyethanol (Sigma-Aldrich, 100 mL) with a stabilizer of ethanolamine (Sigma-Aldrich, 5 mL) (solution A). CNTs (10.5 mg) were subsequently dispersed in ZnO precursor solutions by ultrasonication for 4 hours. A ZnO/CNT precursor solution was maintained under ambient conditions for 24 hours, after which centrifugal separation (15 000 rpm, 30 min, Hanil Science Industrial Co., Ltd., Supra 22K) was performed to separate the homogeneously dispersed supernatant. The well-dispersed supernatant was re-dispersed in solution A without CNT, and finally, a transparent solution without any precipitate was obtained (solution B). To adjust the desired amount of CNTs within a 70 nm thick ZnO layer, the prepared solution B was added in zinc acetate dihydrate–methanol solution (8 wt%). The concentrations of CNTs within the zinc acetate dihydrate–methanol solution were 0.04, 0.08 and 0.12 wt% of zinc acetate dihydrate, respectively (solution C) (see ESI, Fig. S1).

\section*{Inverted organic light-emitting diode fabrication}

F:SnO\textsubscript{2} (FTO) substrates were cleaned by sequential ultrasonication in acetone and isopropyl alcohol (IPA), and dried under a stream of N\textsubscript{2}. A 70 nm thick ZnO/CNT nanocomposite layer was deposited onto the cleaned FTO substrate by the spray-pyrolysis method. The spray pyrolysis was performed at 400 °C on a hotplate using a conventional air-sprayer. The precursor solution C was intermittently sprayed onto the substrate (spraying time: 10 s, interval time for vapouring the solvents: 20 s). The CS\textsubscript{2}CO\textsubscript{3} layer was spin cast onto the ZnO/CNT nanocomposite layer from 0.5 wt% 2-methoxyethanol solution. The poly(9,9’-dioctylfluorene-co-benzothiadiazole) (F8BT) layer was spin cast from a p-xylene solution and annealed at 155 °C for 1 h under a nitrogen atmosphere. Finally, a 10 nm thick MoO\textsubscript{3} layer and a 60 nm thick Au layer were thermally evaporated onto the polymer surface at a slow deposition rate of 0.3 Å s\textsuperscript{−1}.

\section*{Characterization}

A UV-VIS spectrometer (Jasco, V530) was utilized to measure the optical transmittance and the absorbance of ZnO/CNT nanocomposite layers. The surface morphology and roughness of ZnO/CNT nanocomposites were measured by scanning electron microscopy (SEM, Hitachi, S-4700) and atomic force microscopy (AFM, Seiko Instruments, Inc., SPI3800N/SPA400). The work function of ZnO/CNT nanocomposites was obtained from ultraviolet photoelectron spectroscopy (UPS, AXIS-NOVA, Kratos, Inc.). X-ray photoelectron spectroscopy (XPS) measurements were carried out with a Sigma Probe with a microfocused monochromatic X-ray source (Thermo VG Scientific, Inc.). Current density and luminance vs. applied voltage (J–V–L) characteristics were measured using a Keithley 2400 source measurement unit and a Konica Minolta spectroradiometer (CS-2000).

\section*{Results and discussion}

Fig. 1(A) and (B) respectively illustrate the chemical structure of green-light-emitting F8BT and the device architecture of inverted OLEDs used in this work. The device was prepared by sequential deposition of ZnO/CNT nanocomposites (electron transporting layer), CS\textsubscript{2}CO\textsubscript{3} (hole blocking layer), F8BT (light-emitting active layer), MoO\textsubscript{3} (hole transporting layer), and Au (anode) on
a commercially available FTO transparent electrode/glass substrate (cathode). Fig. 1(C) shows the energy level diagram of the fabricated device. The original device architecture with a pure ZnO electron transport layer is known to exhibit hole dominant device characteristics owing to the ohmic contact at the anode mediated by the MoO3 hole transporting layer. Therefore, electron transport enhancement is needed at the cathode to compensate for the hole dominance and to optimize device performance. As reported in our previous work, B-doping of CNTs was performed by thermal treatment with vaporized B2O3 under an Ar–NH3 gas flow mixture. The NH3 was introduced as an etching gas to induce vacancy defects with CNx and CxHy groups. Further reaction with vaporized boron resulted in the substitutional B-doping of CNTs. For N-doping, similar thermal treatment was performed but without B2O3. Quantitative doping-level measurements by XPS, elemental analysis (EA) and inductively coupled plasma-mass spectroscopy (ICP-MS) demonstrate that B-CNT was 3.0 atom% B-doped and 0.5 atom% N-doped, while N-CNT was 3.4 atom% N-doped (ESI, Fig. S2†). A 70 nm thick ZnO/CNT nanocomposite charge transport layer was deposited by spray pyrolysis (ESI, Fig. S1†). The CNT content within the ZnO layer was maintained at 0.08 wt% for maximized OLED performance. Excessive CNTs aggregated and degraded OLED performance (ESI, Fig. S3 and S4†). As shown in Fig. 2(A) and (B), the surface morphology of the prepared ZnO/CNT nanocomposite layer revealed anisotropic, elongated particles that were obviously distinct from those of the pristine ZnO layer. This morphological modification was attributed to the incorporation of long CNTs within ZnO particles. The average surface rms roughness of the ZnO and ZnO/CNT layers measured by AFM showed similar values of 6.6 nm and 8.6 nm, respectively (Fig. 2(C) and (D)). Those values were small enough to reduce the high surface roughness of the FTO electrode (13.5 nm). The UV-VIS spectrum measurements shown in Fig. 2(E) confirmed that the finely dispersed 0.08 wt% CNTs did not significantly influence the optical transmittance of the ZnO layer. The bandgap energy of ZnO/CNT nanocomposite layers also maintained the same value as that of the ZnO layer (~3.2 eV) (ESI, Fig. S5†). A 10 nm thick CS2CO3 layer and a 400 nm thick F8BT layer were sequentially spin cast onto the ZnO/CNT nanocomposite layer, above which a 10 nm thick MoO3 layer and a 60 nm thick Au layer were thermally evaporated to complete the device fabrication.

For efficient electron transport within a ZnO/CNT layer, the work function of metallic CNTs should match the conduction band of the ZnO layer. The electron injection barrier from the cathode to the ZnO/CNT layer was estimated to be 0.5 eV at 4.7 eV, as shown in Fig. 1(B). This barrier was significantly higher than the electron injection energy difference at 4.4 eV, which was attributed to the Ohmic contact at the cathode. Therefore, the energy level alignment of the electron transport layer is critical for efficient electron transport. The UV-VIS spectrum measurements confirmed that the photocurrent and photocurrent efficiency of the ZnO/CNT nanocomposite layer maintained the same efficiency ratio as that of the ZnO layer (ESI, Fig. S6†). The device fabrication was performed by sequential spin casting of the photosensitive layer followed by thermal evaporation of metal electrodes. The device performance is summarized in Table 1. The device fabricated with the ZnO/CNT nanocomposite layer showed a high luminance of 300,000 cd/m2 at 10 V and a high ON/OFF ratio of 10^6. These results demonstrated the high potential of ZnO/CNT nanocomposite layers for efficient electron transport in organic light-emitting diodes (OLEDs).
band of semiconducting ZnO (4.4 eV). The work functions of undoped and doped CNTs were compared by ultraviolet photoelectron spectroscopy (UPS) measurements (ESI, Fig. S6†). While undoped CNTs showed a work function of 4.6 eV, B-CNTs showed a significantly increased value of 5.2 eV. Since B has one fewer electron than carbon, the B-doping lowered the π electron density and, thus, increased the work function. In contrast, the work function of N-CNT decreased down to 4.4 eV due to the additional π electrons from doped N atoms. As schematically illustrated in Fig. 3(A), the Fermi level of N-CNT matched well with the conduction band edge of ZnO. In this ideal ohmic contact, electrons transported freely between semiconducting ZnO and metallic N-CNTs without any barrier such that metallic CNTs of micrometre length provided high mobility pathways to promote the overall electron transport through the ZnO/CNT nanocomposite layer. Meanwhile, the Fermi level of undoped CNT or B-CNT was deeper than the conduction band edge of ZnO. While the electron transport from ZnO to CNT was barrier-free, the reversed transport from CNT to ZnO would encounter an energy barrier. The resultant electron trap in the dispersed CNTs could deteriorate the overall electron transport through the nanocomposite layer.

The electron transport via pure ZnO and ZnO/CNT nanocomposite layers was straightforwardly compared by the characteristics of electron-only devices described in Fig. 3(B). Due to the large energy mismatch between the work function of Al (4.3 eV) and the valence band of ZnO (7.6 eV), hole transport was effectively blocked in this architecture. The current density ($J$) vs. applied voltage ($V$) plots evidently demonstrated the beneficial role of CNTs and the significance of the energy level matching between the conduction band of ZnO and the work function of CNTs in enhancing electron transport. While the B-CNTs with a large energy barrier to ZnO for electron injection caused significantly deteriorated electron transport, the N-CNTs with a barrier-less, ohmic contact revealed remarkable enhancement of electron transport. In the case of undoped CNTs, which had a relatively small energy barrier of ~0.2 eV to ZnO, electron transport was still improved, but only by a small amount.

The light-emitting characteristics of the OLEDs with ZnO and nanocomposite electron transport layers are presented in Fig. 4. Fig. 4(A)–(D) present the current density and luminance vs. applied voltage ($J$–$V$–$L$) plots. The reference OLED without CNTs showed an EL efficiency of 6.9 cd A$^{-1}$ (at 13.4 V) and a luminance of 21 000 cd m$^{-2}$ (at 14.6 V), respectively (Fig. 4(A)). The device with 0.08 wt% B-CNTs exhibited degradation in EL efficiency and luminance down to 4.2 cd A$^{-1}$ (at 14.0 V) and 10 900 cd m$^{-2}$ (at 14.8 V), respectively (Fig. 4(C)). In contrast, the OLEDs with undoped CNTs (Fig. 4(B)) or N-CNTs (Fig. 4(D)) showed enhanced EL efficiency and luminance. The device with N-CNTs exhibited the largest (more than two-fold) enhancement, resulting in luminance of up to 14.3 cd A$^{-1}$ (at 13.6 V) and 46 100 cd m$^{-2}$ (at 14.0 V), respectively. Fig. 4(E) compares the device EL efficiency ($\eta_{EL}$) vs. luminance ($L$), and Fig. 4(F) compares the luminance vs. current density ($L$–$J$) plot. The electron transport enhancement by N-CNTs effectively optimized the electron–hole balance, enhancing the electron–hole recombination probability within the light-emitting F8BT layer. We note that a well-balanced carrier transport was more dominant in the high luminance range. In the low-voltage range
Table 1  Summary of light-emitting characteristics of OLEDs with ZnO electron transport layers incorporated with undoped CNT, B-CNT or N-CNT, and a 400 nm thick light-emitting F8BT layer. The FTO cathode and the MoO₃ deposited Au anode were commonly used for all devices

<table>
<thead>
<tr>
<th>Device configuration</th>
<th>$L_{\text{max}}$ (cd m⁻²) (@ bias)</th>
<th>$\eta_{\text{max}}$ (cd A⁻¹) (@ bias)</th>
<th>$\eta_{\text{max}}$ (lm W⁻¹) (@ bias)</th>
<th>EQE_{\text{max}} (%) (@ bias)</th>
</tr>
</thead>
<tbody>
<tr>
<td>ZnO</td>
<td>21 000 (@ 14.6 V)</td>
<td>6.9 (@ 13.4 V)</td>
<td>1.6 (@ 13.0 V)</td>
<td>2.2 (@ 13.4 V)</td>
</tr>
<tr>
<td>ZnO/undoped CNT (0.08 wt%)</td>
<td>25 000 (@ 14.4 V)</td>
<td>8.9 (@ 12.8 V)</td>
<td>2.2 (@ 12.4 V)</td>
<td>2.8 (@ 12.8 V)</td>
</tr>
<tr>
<td>ZnO/B-CNT (0.08 wt%)</td>
<td>10 900 (@ 14.8 V)</td>
<td>4.2 (@ 14.0 V)</td>
<td>0.9 (@ 14.0 V)</td>
<td>1.3 (@ 14.0 V)</td>
</tr>
<tr>
<td>ZnO/N-CNT (0.08 wt%)</td>
<td>46 100 (@ 14.0 V)</td>
<td>14.3 (@ 13.6 V)</td>
<td>3.5 (@ 13.2 V)</td>
<td>4.3 (@ 13.2 V)</td>
</tr>
</tbody>
</table>

(compare $J-V$ plots in Fig. 4), a weak electron dominant behavior was observed although its physical origin is still unclear. The detailed device characteristics are summarized in Table 1.

The electron and hole transport within the OLEDs with pure ZnO and nanocomposite transport layers were quantitatively compared by the $J-V$ characteristics of the electron-only and hole-only devices (Fig. 5). The electron-only devices were prepared as shown in an inset of Fig. 5(A). Due to the large hole injection barrier at the Ca/Al anode, electrons were dominant carriers in this modified device architecture. Without hole injection, the electron-only devices did not show any noticeable electroluminescence. As shown in Fig. 5(A), the devices with ZnO/CNT nanocomposite layers reached an electron injection current density of 0.35 mA cm⁻² at 4.5 V for N-CNTs, at 8.0 V for undoped CNTs, and at more than 15 V for B-CNTs, respectively. The device with a pure ZnO electron transport layer reached the same current density at 12.8 V. The electron mobility was calculated using the Mott–Gurney space-charge-limited-current (SCLC) equation:

$$J = \frac{9}{8} \mu_{\text{eff}} \varepsilon_0 \varepsilon_r V^2 \frac{d}{d}$$

where $J$ is the current density, $\mu_{\text{eff}}$ is the effective charge carrier mobility, which includes the effect of injection efficiency or traps, $\varepsilon_0$ is the permittivity of free-space, $\varepsilon_r$ is the relative dielectric constant, $V$ is the applied voltage, and $d$ is the thickness of the active layer. The $J-V$ characteristics of electron-only devices were fitted with the SCLC model shown in eqn (1) (Fig. 5(B)). By the literature of employing the relative dielectric constant (2.9)⁴³ and the measured thickness of 400 nm for F8BT layer, the effective electron mobility ($\mu_{\text{eff}}$) was calculated to be $1.5 \times 10^{-6}$ cm² V⁻¹ s⁻¹ for the device without CNT, $4.0 \times 10^{-6}$ cm² V⁻¹ s⁻¹ for the device with undoped CNTs, and $8.0 \times 10^{-6}$ cm² V⁻¹ s⁻¹ for the device with B-CNTs, respectively. In contrast, the device with N-CNTs showed the highest effective mobility of $7.0 \times 10^{-6}$ cm² V⁻¹ s⁻¹, which corresponded to a five-fold improvement over the device without CNTs. Under the reasonable assumption that the bulk mobility of the F8BT layer did not change, the observed difference in $\mu_{\text{eff}}$ should be caused by the difference in the layers underneath the F8BT layer. The hole-only device consisting of Sn:In₂O₃ (ITO), poly(3,4-ethylene dioxythiophene):poly(styrene sulfonate) (PEDOT:PSS), F8BT, MoO₃, and Au layers was investigated for hole mobility (Fig. 5(C)). Owing to the large energy gap between the PEDOT:PSS and F8BT layers, electron transport was blocked in this architecture. Mott–Gurney SCLC fitting estimated effective hole mobility ($\mu_{\text{eff}}^\text{h}$) of $6.0 \times 10^{-6}$ cm² V⁻¹ s⁻¹. A quantitative comparison of electron and hole mobilities verified that the device with a ZnO/N-CNT nanocomposite electron transport layer had a balanced electron and hole transport (Fig. 5(D)), which was greatly advantageous for high performance optoelectronic devices.

Conclusions

We have demonstrated a metal oxide/chemically doped CNT nanocomposite charge transport layer with improved charge injection and transport properties, and its successful application in high performance OLEDs. Unlike other methods to promote the electrical conductivity of metal oxides, such as foreign element doping, reinforcement with high carrier mobility nanomaterials could effectively enhance the electron mobility of metal oxides, maintaining the optical transparency, solution process-ability, and intrinsic bandgap energy levels. This offered an unprecedented opportunity to enhance the device performance of inverted OLEDs with minimized alteration of the device architecture and fabrication process. Additionally, due to the tunability of the CNT work function by substitutional doping, our CNT-assisted charge mobility enhancement is generally
useful for various organic and inorganic charge transport materials with different energy levels.  

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Notes and references

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